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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/645,698	08/20/2003	Makoto Yokota	245402007300 9292	
25226 7	590 04/12/2005		EXAMINER	
MORRISON & FOERSTER LLP 755 PAGE MILL RD			MENEFEE, JAMES A	
PALO ALTO, CA 94304-1018			ART UNIT	PAPER NUMBER
			2828	
			DATE MAILED: 04/12/2005	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)			
	10/645,698	уокота, макото			
Office Action Summary	Examiner	Art Unit			
	James A. Menefee	2828			
The MAILING DATE of this communication a Period for Reply	appears on the cover sheet with the	correspondence address			
A SHORTENED STATUTORY PERIOD FOR REF THE MAILING DATE OF THIS COMMUNICATION - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a r - If NO period for reply is specified above, the maximum statutory perion - Failure to reply within the set or extended period for reply will, by state Any reply received by the Office later than three months after the may earned patent term adjustment. See 37 CFR 1.704(b).	N. 1.136(a). In no event, however, may a reply be to reply within the statutory minimum of thirty (30) do do will apply and will expire SIX (6) MONTHS frow tute, cause the application to become ABANDON	timely filed ays will be considered timely. m the mailing date of this communication. IED (35 U.S.C. § 133).			
Status					
1) Responsive to communication(s) filed on	·				
2a) ☐ This action is FINAL . 2b) ☑ T	his action is non-final.				
3) Since this application is in condition for allowance except for formal matters, prosecution as to the ments is					
closed in accordance with the practice unde	er Ex parte Quayle, 1935 C.D. 11, 4	453 O.G. 213.			
Disposition of Claims					
4) Claim(s) <u>1-8</u> is/are pending in the application 4a) Of the above claim(s) is/are withd 5) Claim(s) is/are allowed.					
6) Claim(s) is/are rejected.					
7) Claim(s) is/are objected to.					
8) Claim(s) <u>1-8</u> are subject to restriction and/or	r election requirement.				
Application Papers					
9) The specification is objected to by the Exami	iner.				
10) ☐ The drawing(s) filed on is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.					
Applicant may not request that any objection to the	he drawing(s) be held in abeyance. S	ee 37 CFR 1.85(a).			
Replacement drawing sheet(s) including the corr					
11)☐ The oath or declaration is objected to by the	Examiner. Note the attached Office	e Action or form PTO-152.			
Priority under 35 U.S.C. § 119					
12) Acknowledgment is made of a claim for forei a) All b) Some * c) None of:		a)-(d) or (f).			
1. Certified copies of the priority docume					
2. Certified copies of the priority docume	•				
 Copies of the certified copies of the properties of the	•	ved in this National Stage			
* See the attached detailed Office action for a li	* * * * * * * * * * * * * * * * * * * *	ved.			
•					
Attachment(s)	_				
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	4)	ry (PTO-413) Date			
 Notice of Dransperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/0 Paper No(s)/Mail Date 		Patent Application (PTO-152)			
Patent and Tradamark Office	-,				

Application/Control Number: 10/645,698

Art Unit: 2828

DETAILED ACTION

Election/Restrictions

Restriction to one of the following inventions is required under 35 U.S.C. 121:

- I. Claims 1-6, drawn to a semiconductor laser, classified in class 372, subclass 49.
- II. Claims 7-8, drawn to a method of fabricating a semiconductor laser, classified in class 438, subclass 22+.

The inventions are distinct, each from the other because of the following reasons:

Inventions II and I are related as process of making and product made. The inventions are distinct if either or both of the following can be shown: (1) that the process as claimed can be used to make other and materially different product or (2) that the product as claimed can be made by another and materially different process (MPEP § 806.05(f)). In the instant case the product could be made by a materially different process. The process invention requires either growth of the silicon oxide film by resistance heating vapor deposition, or requires growth of that film along with another film, both films formed in the same chamber. Clearly the films could be grown in separate chambers, which would be directly the opposite and therefore a materially different process. Also, different types of growth besides resistance heating vapor deposition could be used.

It is noted that should applicant elect the product claims, rejoinder of the method claims may be possible under MPEP 821.04 upon allowance of the products.

Because these inventions are distinct for the reasons given above and have acquired a separate status in the art as shown by their different classification, restriction for examination purposes as indicated is proper.

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Applicant is advised that the reply to this requirement to be complete must include an election of the invention to be examined even though the requirement be traversed (37 CFR 1.143).

Any inquiry concerning this communication or earlier communications from the examiner should be directed to James A. Menefee whose telephone number is (571) 272-1944. The examiner can normally be reached on M-F 8:30-5.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, MinSun Harvey can be reached on (571) 272-1835. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

James Menefee April 8, 2005